



Yttrium Oxide SPUTTERING TARGET

Yttrium oxide is a chemical compound with a chemical formula of Y_2O_3 . Yttrium oxide is used as a common starting material for both materials science as well as inorganic compounds. It is evaporated under vacuum for the fabrication of semiconductors and passive components.

Quick Facts

Product	:	Yttrium Oxide Sputtering Target
Stock No	:	NS6130-10-1138
CAS	:	1314-36-9
Backing Plate	:	(As per Customer requirement)

Additional Characteristics

Stock No.	Purity	Diameter	Thickness
NS6130-10-1138	99.99%	50.8 mm \pm 1mm	3 mm \pm 0.5mm

Technical Specification

Molecular Formula	Molecular Weight	Melting Point
Y_2O_3	225.81g/mol	2425°C



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19ZAZG01274G

20ZICE4588M

20ZICE4589C

High Purity
SPUTTERING
TARGET